

DIRECTOR, U.S. PATENT AND TRADEMARK OFFICE WASHINGTON, DC 20231

In re Application of:

MEARS

Serial No.:

10/647,060

Filed:

AUGUST 22, 2003

For:

SEMICONDUCTOR DEVICE INCLUDING BAND-ENGINEERED SUPERLATTICE

Sir:

Transmitted herewith is an INFORMATION DISCLOSURE STATEMENT in the above-identified application.

- 1. [X] This IDS is submitted under 37 C.F.R. § 1.97. No fee is required.
- 2. [] This IDS is submitted under 37 C.F.R. § 1.97(c). Enclosed is a check in the amount of \$ 180.00 .
- 3. [] This IDS is submitted under 37 C.F.R. § 1.97(c) and (e). No fee is required.
- 4. [] This IDS is submitted under 37 C.F.R. § 1.97(d) and (e). Enclosed is a check in the amount of \$130.00 to cover the petition fee.
- 5. [X] The Commissioner is hereby authorized to charge or credit any discrepancies in fee amounts to Deposit Account No. 01-0484.
- 6. [X] Please associate this application with Customer No. 27975.

27975

PATENT TRADEMARK OFFICE

Date: October 2, 2003

CHRISTOPHER F. REGAN

Reg. No. 34,906

UNITED STATES PATENT AND TRADEMARK OFFICE

ent Application of:

MEARS

Serial No. 10/647,060

Filing Date: AUGUST 22, 2003

For: SEMICONDUCTOR DEVICE INCLUDING)

BAND-ENGINEERED SUPERLATTICE

CITATION UNDER 37 CFR §1.97

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is Form PTO-1449 listing several references for consideration in the examination of the above-identified application. A copy of each reference is also enclosed. is requested that these references be considered by the Examiner and officially made of record in accordance with the provisions of 37 CFR §1.97 and Section 609 of the MPEP.

Respectfully submitted

CHRISTOPHER F. REGAN

Reg. No. 34,906

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Attorney for Applicants

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: COMMISSIONER FOR PATENTS, P.O. BOX 1450, ALEXANDRIA, VA 22313-1450, on this day of October, 2003.

OT 0 6 2003 &

INFORMATION DISCLOSURE

Atty Docket: Serial No.: Applicant: Filing Date:

Group:

62601 10/647,060 MEARS

AUGUST 22, 2003

U.S. PATENT DOCUMENTS							
Examiner Initials		Document Number	Date	Name	Class	Sub Class	Filing Date
	AA	4,594,603	06/10/86	Holonyak, Jr.	357	16	01/24/85
	AB	4,937,204	06/26/90	Ishibashi et al.	437	110	01/4/89
	AC	4,969,031	11/06/90	Kobayashi et al.	357	63	02/3/83
	AD	5,05,887	10/08/91	Yamazaki	357	4	01/18/90
	AE	5,216,262	06/1/93	Tsu	257	17	03/2/92
	AF	5,357,119	10/18/94	Wang et al.	257	18	02/19/93
	AG	5,684,817	11/04/97	Houdre et al.	372	45	05/1/96
	АН	5,683,934	11/4/03	Candelaria	437	134	05/3/96
	Al	5,994,164	11/30/99	Fonash et al.	438	97	03/18/98
	AJ	6,058,127	05/2/00	Joannopoulos et al.	372	92	12/12/97
	AK	6,274,007	08/14/01	Smirnov et al.	204	192	03/14/00
	AL	6,281,518	08/28/01	Sato	257	13	12/3/98
	АМ	6,281,532	08/28/01	Doyle et al.	257	288	06/28/99
	AN	6,344,271	02/05/02	Yadav et al.	428	402	03/23/99
	AO	6,472,685	10/29/02	Takagi	257	77	12/2/98
	AP	6,498,359	12/24/02	Schmidt et al.	257	190	05/18/01
	AQ	2003/ 0034529	02/20/03	Fitzgerald et al.	257	369	10/8/02
	AR	2003/ 0057416	03/27/03	Currie et al.	257	19	09/20/02
			FOREIGN	PATENT DOCUMENTS	\$		
		Document Number	Date	Country	Class	Sub Class	Translation
	AS	02/103767	12/27/02	wo	H01L	21/20	
	AT	2,347,520	09/06/00	GB	G02B	5/18	
	AU						

EXAMINER:	DATE CONSIDERED:

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



INFORMATION DISCLOSURE
STATEMENT

Atty Docket: Serial No.: Applicant:

62601 10/647,060 MEARS

Filing Date: Group: AUGUST 22, 2003

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)						
AV	Xuan Luo et al.; "Chemical Design of Direct-Gap Light-Emitting Silicon", published July 25, 2002 by The American Physical Society; Vol. 89, Number 7					
AW	R. Tsu; University of North Carolina at Charlotte, "Phenomena in Silicon Nanostructure Devices"; published 09/06/2000 © Springer-Verlag 2000					
AX	P.D. Ye et al., "GaAs MOSFET with Oxide Gate Dielectric Grown by Atomic Layer Deposition"; © 2003 Agere Systems, March 2003					
AY	Novikov et al.; "Silicon-based Optoelectronics" © 1999-2003 by John Wiley & Sons, Inc.; pp/ 1-6					
AZ						
ВА						

EXAMINER:	DATE CONSIDERED:

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